

DOCKET NO: 278426US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :
MITSUGU ABE, ET AL. : EXAMINER: ROSE, R.
SERIAL NO: 10/549,294 : GROUP ART UNIT: 3727
FILED: SEPTEMBER 16, 2005 : RCE FILED: HERewith
FOR: MATERIAL FOR PURIFICATION :
OF SEMICONDUCTOR POLISHING
SLURRY, MODULE FOR PURIFICATION
OF SEMICONDUCTOR POLISHING
SLURRY AND PROCESS FOR
PRODUCING SEMICONDUCTOR
POLISHING SLURRY

AMENDMENT

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Final Rejection dated February 6, 2009, and further to the Request for Continued Examination ("RCE") filed herewith, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 10 of this paper.